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September 10, 2003



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MAIL STOP PATENT APPLICATION

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Re:

Application of Tsutomu SHOKI

METHOD OF PRODUCING A REFLECTIVE-TYPE MASK BLANK,

METHOD OF PRODUCING A SEMICONDUCTOR DEVICE

Assignee: HOYA CORPORATION

Our Ref. Q77434

Dear Sir:

Attached hereto is the application (Japanese Language) identified above comprising twenty-one (21) sheets of the specification, including the claims and abstract, and four (4) sheets of drawings. The Requisite U.S. Government Filing Fee, English Translation, executed Declaration and Power of Attorney and Assignment will be submitted at a later date.

The Government filing fee is calculated as follows:

Total claims Independent claims Base Fee	<u>12</u> - 20 <u>1</u> - 3	=	x x	\$18.00 \$84.00	= -	\$.00 \$.00 \$750.00
TOTAL FEE						\$750.00



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Priority/Benefit is claimed from:

Country

Application No

Filing Date

JAPAN

2002-265044

September 11, 2002

The priority document will be filed at a later date.

Respectfully submitted, SUGHRUE MION, PLLC

Attorneys for Applicant

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